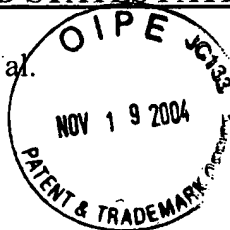


cp 2815  
PATENT ✓ Hw

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Lap Wai Chow, et al.



Examiner: Nguyen, Joseph H.  
Art Unit: 2815

Patent Appl: 09/768,904

Our Ref: B-3964 618029-8

Filed: January 24, 2001

Date: November 15, 2004

For: "INTEGRATED CIRCUITS "  
PROTECTED AGAINST REVERSE  
ENGINEERING AND METHOD FOR  
FABRICATING THE SAME USING AS  
APPARENT METAL CONTACT LINE  
TERMINATING ON FIELD OXIDE"

Re: *Second Request for  
Reconsideration*

**SECOND REQUEST FOR RECONSIDERATION**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

The Applicant is filing this Second Request for Reconsideration of the final rejection issued in the above-identified application because the Examiner sets forth, for the first time, in the response to the first request for reconsideration that was filed, a new position that the Examiner had not heretofore taken.

**Remarks/Arguments** begin on page 2 of this paper.